

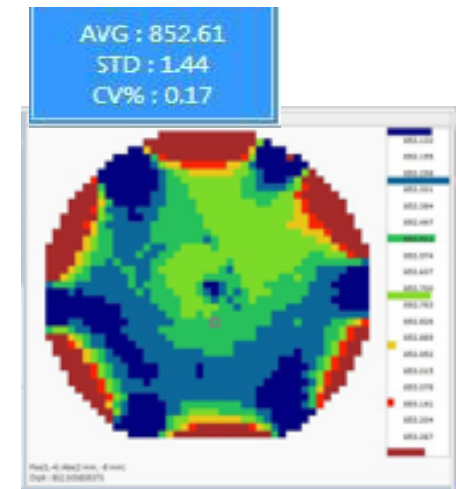
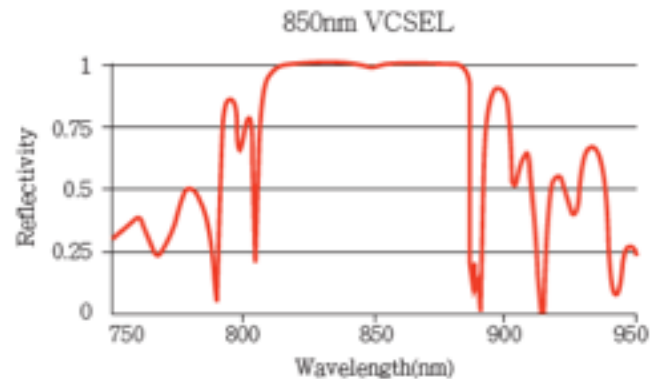
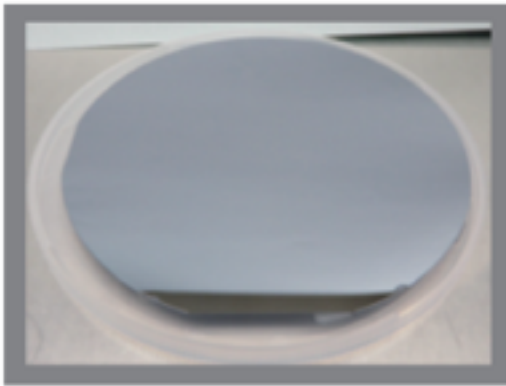
VCSEL Epi Wafer

Wafer size: 3"/ 4"/ 6"

Wavelength: 850/ 940nm/Customer design

Process type : Ion implantation and Oxidation

Application : 3D imaging, IR light source, Optical communication, Automobile, Sensing.



940nm VCSEL with power > 1W and SE > 0.8 @ 1.5A is available now !

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